EAST Search History

Ref#	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
**************************************	0	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution near5 inlet with diagonal and distribution adj3 plate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 12:55
8	0	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution near5 inlet and distribution adj3 plate and lead adj2 flame	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 12:56
53 S3	0	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution near5 inlet and distribution near10 nozzle and lead adj2 flame	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 12:56
S4	0	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution near5 inlet and nozzle and lead adj2 flame	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 12:56

S5	13	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution near5 inlet and distribution near10 nozzle	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 12:57
S 6	18	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution near5 sparger and nozzle	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 12:58
S7	27	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution with flow near5 distribution and nozzle	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:00
S8	6	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution with plate near5 distribution and nozzle	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:02
S9	411	(electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and plate near5 distribution and nozzle	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:03

S10	10	(electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution with plate near5 distribution and nozzle and (lead adj2 frame sheet Web)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:03
S11	10	(electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution with plate near5 distribution and nozzle and (lead adj2 frame sheet foil Web)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:04
S12	53	(electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution with flow near5 mixing and nozzle and (lead adj2 frame sheet foil Web)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:05
S13	35	(electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution with flow near5 mixing and nozzle not S12	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:07
S14	16	(electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and side adj2 inlet with mixing	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:14
S15	73	(electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and side adj2 inlet with solution	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:19

S16	959	side adj2 inlet with solution	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:29
S17	8	side adj2 inlet with solution and flow adj2 distribution	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:30
S18	12	side adj2 inlet with solution and distribution near5 plate	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:31
S19	56	side adj2 inlet with solution and flow near5 mix\$3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:51
S20	3697	inlet with solution and flow near5 mix \$3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:53
S21	3	Diagonal with inlet with solution and flow near5 mix\$3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:54
S22	7	side adj2 inlet with solution and flow near5 agitat\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:55
S23	0	side adj2 inlet with solution and flow near5 sparger	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:56

S24	6	side adj2 inlet with solution and sparger	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:56
\$25	390	inlet with solution and sparger	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 13:56
S26	41	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution near5 inlet with recirculat\$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 15:02
S27	175	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution with side near10 inlet	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 15:13
S28	175	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution with side near10 inlets	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 15:14
S29	154	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution near10 inlet and membrane and wafer	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 15:38

\$30	44	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution near10 inlet and membrane and wafer and recirculat \$4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 15:38
S31	12	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution near10 inlet with multiple	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 15:49
S32	40	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution near10 inlet near5 two	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 15:51
S33	525	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and inlet near5 two not \$32	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 15:54
S34	14	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and inlet near5 two with mixing not \$32	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 15:54

S35	46	("205"/\$.ccls. "204"/ \$.ccls.) and (electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and solution with inlet near5 two	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 16:07
S36	111	(electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and solution with inlet near5 two not \$35	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 16:19
S37	1	(electrolytic electrochemic\$4 plating electrodeposit\$5 electroplat\$5) and solution with (inlet near5 two) same diagonal	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 16:22
S38	3	solution with (inlet near5 two) same diagonal	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 16:23
S39	8	solution with inlet near5 diagonal	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 16:24
S40	8	("118"/\$.ccls.) and solution with inlet near5 two	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/09/08 16:56

9/11/2008 11:26:03 AM

 $C:\ Documents\ and\ Settings\ Ivan1\ My\ Documents\ EAST\ Workspaces\ 10538391\ side\ inlet.wsp$